Appl. No. 10/565,323 Response dated March 1, 2010 Reply to Office action of October 27, 2009

In the claims:

Please amend claims 1-4 as follows:

 (currently amended) A colloidal crystal preparation process, wherein compressed air pulses are generated by control of a compressed gas, and then guided to comprising the steps of:

forming a gas pulse from a compressed gas by using gas pulse formation means and outputting the formed gas pulse; and

applying the gas pulse to a colloidal crystal preparation vessel having a flat plate capillary portion to produce a pressure fluctuation therein, which is used as driving power, thereby giving a flow and hard-stopping motion to a colloidal solution in said flat plate capillary for formation of colloidal crystals of good single crystallinity portion, wherein a colloidal solution filled in the flat plate capillary portion is made to flow at a pressure rise phase and a constant pressure phase of the applied gas pulse, and the flow of the colloidal solution is stopped at a pressure drop phase of the applied gas pulse.

2. (currently amended) A <u>colloidal crystal gel</u> process—ofpreparation of a colloidal crystal gel having good singlecrystallinity, wherein subsequent to said step of formingcolloidal crystals of good single crystallinity as recited inAppl. No. 10/565,323 Response dated March 1, 2010 Reply to Office action of October 27, 2009

claim 1, a step of gelating the formed colloidal crystals is applied, comprising the steps of:

forming a gas pulse from a compressed gas by using gas pulse formation means and outputting the formed gas pulse;

applying the gas pulse to a colloidal crystal preparation vessel having a flat plate capillary portion, wherein a colloidal solution containing high-molecular gelation agent filled in the flat plate capillary portion is made to flow at a pressure rise phase and a constant pressure phase of the applied gas pulse, and the flow of the colloidal solution is stopped at a pressure drop phase of the applied gas pulse; and

gelating the high-molecular gelation agent in the colloidal crystal containing high-molecular gelation agent obtained through the gas pulse applying step.

3. (currently amended) A colloidal crystal preparation system, comprising:

compressed gas feeder means[[,]];

gas pulse formation means for producing a compressed gas asshort-time gas pulses, forming a gas pulse from the compressed gas fed by the compressed gas feeder means and outputting the formed gas pulse; and

a colloidal crystal preparation vessel having a flat plate capillary portion for formation of that receives application of the gas pulse to form a colloidal erystals crystal, wherein

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the gas pulse formation means forms a gas pulse whose pressure rise phase and constant pressure phase make a colloidal solution to flow and whose pressure drop phase stops the flow of the colloidal solution and outputs the formed gas pulse.

4. (currently amended) A colloidal crystal gel preparation
system[[,1] comprising:

compressed gas feeder means[[,]];

gas pulse formation means for producing a compressed gas as short-time a gas pulses, pulse from the compressed gas fed by the compressed gas feeder means and outputting the formed gas pulse; and

a colloidal crystal preparation vessel having a flat plate capillary portion for formation of colloidal crystals, that receives application of the gas pulse to form a colloidal crystal containing high-molecular gelation agent; and

gelation acceleration means, for gelating the high-molecular gelation agent in the colloidal crystal, wherein

the gas pulse formation means forms a gas pulse whose

pressure rise phase and constant pressure phase make a colloidal

solution to flow and whose pressure drop phase stops the flow of
the colloidal solution and outputs the formed gas pulse.